12th International Conference on Gas Discharge Plasmas and Their Applications IOP Publishing Journal of Physics: Conference Series **652** (2015) 012029 doi:10.1088/1742-6596/652/1/012029

# **Synthesis of Polycrystalline Diamond Films in Abnormal Glow Discharge and their Properties**

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**Abstract.** The optical and electrophysical properties of polycrystalline diamond films (PDF) deposited from the abnormal glow discharge have been studied. The dominating mechanisms of absorption and charge carrier transfer and the energy spectrum of the localized states (LS) of defects which determine the properties of the films have been specified. The parameters of the interband absorption and electrical conductivity are determined by the continuous energy distribution in the band gap (BG) of the states of defects of different nature. The absorption edge of the crystalline phase of the films is separated from the absorption zone determined by the electron transitions between LS defects. The width of BG is narrowed to 0.2–0.5 eV from the quantity typical to the diamond. An additional film absorption edge is formed in the energy interval 1.2–3.3 eV, where Urbach rule is fulfilled and the interband absorption is realized at direct transitions through the optical gap 1.1–1.5 eV. The average width of BG is 2.6–3.24 eV estimated within semiclassical interband model. The interaction of the parameters of the interband and exponential absorption is determined by the crystal lattice static disorder. The dominating n-type of the activation component of the electrical conductivity is complemented by the hopping mechanism with the participation of the localized states of the defects distributed near the Fermi level with a density  $5.6 \cdot 10^{17} - 2.1 \cdot 10^{21}$  eV<sup>-1</sup>·cm<sup>-3</sup>.

**Keywords**: polycrystalline diamond films, absorption, electrical conductivity, photoconductivity, localized states of defects

#### **1. Introduction**

The unique chemical, mechanical, electrical and thermophysical, optical and photoelectrical properties of a diamond contribute to its wide application in high-frequency and high-temperature electronics [1– 5]. Due to the limited potentials for application of diamond single crystals and epitaxial diamond films caused by their high cost, the most appropriate instruments are the polycrystalline diamond films (PDF), which are obtained by well-studied methods of the gas-phase deposition [1–9]. PDF are successfully used for the production of the stable radiation-resistant UV detectors and ionizing radiation, as well as for laser and photodiode structures [1,4–7]. Depending on the characteristics of PDF polycrystalline structure, the content of alloying impurity atoms and defects in the PDF crystal structure, their optical and electrical characteristics vary widely. It stimulates the study of the electrophysical and optical properties of PDF, the investigation of the mechanisms determining these properties and the influence of deposition conditions on the change in the characteristics. The method

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of the film deposition from abnormal glow discharge (AGD) plasma stands out among various methods of PDF deposition – using microwave discharge plasma, hot filament, and plasma-arc CVD. Each of the methods has a lot of disadvantages: high cost and/or limitations in maximum deposition area; low rate and the necessity to repeated replacement of filaments; the drawback of a plasma-arc CVD method is a small deposition area and high gas consumption. The efficiency of the method of PDF deposition from AGD plasma compared to the alternative ones is in its simplicity and a high growth rate.

The aim of the work is to determine the optical, electrical, and photoelectrical characteristics, the energy spectrum of the defect levels and their nature in PDF deposited from AGD plasma.

#### **2. Research methods**

The methods of film deposition from AGD and the study of the film structural features are described in detail in [2, 3]. A new system of diamond film deposition from AC of AGD has been presented. In the process of deposition the discharge in the form of the plasma filament is realized between two small electrodes, and the distance between electrodes reaches 20 cm. The electrodes are removed from the substrate, and the material of the electrodes does not contaminate the film [2]. The absorption spectra of  $\alpha$ (hv) were calculated from the diffuse reflection spectra and were approximated by the Urbach rule to determine the characteristics of the localized states (LS) of defects distributed in the band gap (BG) of the films and by the laws for the interband absorption of crystalline and amorphous semiconductors [10]. The dark surface conductivity  $\sigma$  and photoconductivity  $\Delta \sigma_{ph} = \sigma_{ph} - \sigma$  ( $\sigma_{ph}$  is conductivity under lighting), photosensitive K(U, T, hv)= $\Delta\sigma_{ph}/\sigma$  were measured at a constant voltage across the electrodes U=0.01–300 V, at temperature  $T=300-700$  K, and photon energy hv=1.5–4.0 eV. The electrodes were deposited on the surface by rubbing the soft graphite. The temperature dependences of  $\sigma \Delta \sigma_{ph}(\mathsf{T})$  were approximated by the equation for the activation mechanism

$$
\sigma_a(T) = \sigma_0 \times e^{(-\varepsilon_{\sigma}/k \cdot T)}
$$
 (1)

( $\sigma_0$  is a pre–exponential factor,  $\varepsilon_{\sigma}$  is an activation energy, k is the Boltzmann constant) and by the equation for the hopping mechanism of transfer between LS near the Fermi level  $E_F$  within the Mott model

$$
\sigma_p(T) = \sigma'_0 \times e^{(-(T_0/T)^{0.25})}, \qquad (2)
$$

( $\sigma'$ <sub>0</sub> is a pre–exponential factor, T<sub>0</sub> is activation energy) [11, 12]. The LS density N(E<sub>F</sub>) near E<sub>F</sub> was calculated from  $T_0$  according to [11, 12]. The sign of the dominant charge carriers was determined by the photostimulated current amplitude  $I_{PhTSC}(T, hv, U=0)$  [11].

#### **3. Results and discussion**

The  $\alpha$ (hv) spectra indicate the heterogeneity of defect pattern with LS when hv=1.1–5.5 eV (figure 1). The concentration of LS defects vary from  $N=2.10^{19}$  to  $3.10^{20}$  cm<sup>-3</sup> across the surface of the film deposition and over their thickness (figure 1). The surface roughness has a greater effect on the properties than the size of the crystallites [1]. The accumulation of LS with an energy of  $hv=1.1-1.9$ and 2.5–4.5 eV is higher from the side of the substrate than from the growth side (figure 1). The characteristics of  $\alpha$ (hv) spectra indicate the dominant defect agglomeration near the intercrystalline boundaries of PDF and the impact of the amorphous hydrogenated carbon a–C:H by analogy with [1, 6–9]. A sharp rise of  $\alpha$  when hv>5.0 eV responds the fundamental absorption in crystallites (figure 1). The width of BG films  $E_g = 5.0 - 5.27$  eV for direct transitions when hv=5.2–5.6 eV is close to  $E_g = 5.45$  eV of diamond and  $E_g = 5.0 - 5.5$  eV of CVD films [1, 4–5]. The absorption in PDF crystallites (hv=5.0–5.6 eV) is separated from the absorption zone (hv=1.1–5.0 eV) caused by defect LS (figure 1). BG narrowing by 0.1–0.2 eV is more explicitly from the side of the substrate to the edge of deposition. The spectra indicate the realization within the interval  $hv=1.1-5.0$  eV of several types of absorption. Within the intervals hv=1.18–1.3, 1.3–1.8, and 1.8–2.3 eV the spectra  $\alpha$ (hv) obey the Urbach rule

$$
\alpha(h\nu) = \alpha_0 \times e^{(-h\nu/E_U)} \tag{3}
$$

with the PDF typical parameters  $\alpha_0$  and E<sub>U</sub> (E<sub>U</sub> is Urbach energy) (figure 1). In the intervals hv=1.18– 1.3 eV the value  $E_U$ =0.05–0.2 eV is close to the value  $E_U$  in a–C:H [8]. The big values  $E_U$ >1.6 eV within the intervals hv=1.3–1.8, 1.8-2.3 eV in the films are typical to nanocrystalline diamond films (NCDF) [1, 5, 6, 9, 13, 14]. Increasing  $E_U$  with the depth of the level in BG is determined by the high overlapping of exponentially distributed LS and enables the realization of interband absorption at the distance from the edge of BG. The characteristics of exponentially distributed levels in BG are determined by a high impact of graphite-like phase disordered by the defects [1, 6–9].

The spectra  $\alpha$ (hv) are also approximated by the law for the interband absorption

$$
\alpha \times h \nu = B'(B'') \times (h \nu - E'_g(E''_g))^m, \tag{4}
$$

where m=1/2 and 2 for direct and indirect allowed transitions through the optical bands  $E'_{g}$  and  $E''_{g}$ , respectively. For the indirect transitions realized within the interval hv=1.2–2.4 eV, E<sup> $\sim$ </sup>  $\leq$  0 eV, and for the direct within the interval hv=1.5–3.4 eV the BG width is  $E'_{g}=1.1-1.6$  eV (figure 2). It indicates the probable overlapping of LS with the allowed bands caused by the increase in the content of  $sp^2$ clusters and their sizes by analogy with [1]. In NCDF the close interrelations (E''<sub>g</sub>=1.0 eV, E'<sub>g</sub>=2.2 eV) are determined by the defect LS near the grain boundaries [15, 16]. In the films a–C and a–C:H  $E^{\prime\prime}$ <sub>g</sub>=1–3 and 1.5–3.5 eV [8]. In PDF  $E^{\prime\prime}$ <sub>g</sub> is narrower than in the diamond-like carbon films (DLCF) and ultradispersed nanodiamond films (UDNDF), where  $E^{\prime}{}_{g}=3.3-3.5$  eV. The interval overlap of the interband and exponential absorption suggests that a new edge of absorption is formed in PDF biased to the zone  $hv=1.2-3.3$  eV, where the Urbach rule is followed and the interband absorption is realized. The decrease in  $E_g$  with  $E_U$  growing is typical to LS with hv=1.18–1.3 and 1.8–2.3 eV (figure 3). The similar interrelation  $E''_g$  and  $E_U$  is typical to the films a–C, a–C:H [8] and to the materials with a high concentration of defects [10].

The effect of the structural disorder in PDF is estimated and within the semiclassical model for the interband absorption of amorphous or highly defect materials [1, 10]. Here the spectra obey the law

$$
\alpha(h\nu) = \alpha_0'' \times e^{(-(h\nu - E_{g0})^2/2\sigma^2)}, \qquad (5)
$$

where  $\alpha'_{0}$  is a multiplier,  $E_{g0}$  is a mean BG width ( $E_{g}$  obeys the Gaussian distribution relative to  $E_{g0}$ ,  $\sigma^2$  is the dispersion of the value E<sub>g</sub> determined by the disorder induced by defects) (figure 1, curve 2). The dispersion  $\sigma$  is close to the value E<sub>U</sub> for the defects localized when hv=1.3–1.8 eV. The values E'<sub>g</sub> and  $E_{g0}$  correlate due to the equality of both interband absorption models (figure 3). Since the overlapping degree of the defect levels is growing ( $E_U$ ), the mean BG width  $E_{g0}$  is decreased (figure 3). The values  $\alpha_0$ " and B' (proportional to the density of states bound by the interband transitions through the optical gap) vary in the correlation when  $E_{g0}$  is changed (figure 4). The values  $E_{g0}$  in PDF are close to the optical gap of DLCF  $E''_{g}=3.77$  eV and UDNDF  $E_{g}=3.3-3.5$  eV. The PDF spectra  $\alpha(hv)$ correspond to the transition model between the states  $\pi-\pi^*$  determined by the border inclusions a–C, through the pseudogap  $E_{g0}$ =3.0–3.5 eV [1, 6, 7, 9, 17]. The correlations between the parameters  $E_{g}$ ,  $E_{g0}$ and  $\sigma$ ,  $E_{U}$  are typical to the materials with the static and/or dynamic disorder of the crystal lattice (figures 3 and 4) [10, 14–16]. It indicates the impact of the absorption in crystallites on the properties, and it suggests that PDF is the material with the BG width for direct transitions 1.1–1.6 eV and the absorption edge determined by the defect LS with  $\varepsilon$ =1.2–3.3 eV.

Spectrum factorization on the elementary Gaussian curves  $\alpha$ -exp(-(hv-E)<sup>2</sup>/(0.833 $\gamma$ <sup>2</sup>) (E is the center,  $\gamma$  is half-width) identify the local defect levels: **1**–E=1.17 eV,  $\gamma$ =0.1 eV, N=2⋅10<sup>19</sup> cm<sup>-3</sup> (V<sup>+</sup> is the center [14]); **2**–1.4 eV, 0.3 eV, 1.2⋅10<sup>20</sup> cm<sup>-3</sup>; **3**–(1.8–2) eV, 0.4 eV, 7⋅10<sup>20</sup> cm<sup>-3</sup> (GR1, I<sup>0</sup> are the centers [18]); **4**–(2.1–2.2) eV, 0.2 eV, 2⋅10<sup>19</sup> cm<sup>3</sup> (sp<sup>2</sup>( $\pi \rightarrow \pi^*$ ) [1, 7]); **5**–(2.6–2.7) eV, 0.5 eV, 2⋅10<sup>20</sup> cm<sup>-3</sup>  $(\text{sp}^2(\pi \rightarrow \pi^*)$  [1, 7]); **6**–(3.2–3.4) eV, 0.4 eV,  $3 \cdot 10^{20}$  cm<sup>3</sup> (V<sup>-</sup>,  $\text{sp}^2(\pi \rightarrow \pi^*)$  [1, 6]); **7**–(3.9–4.1) eV,  $0.4$  eV,  $2 \cdot 10^{20}$  cm<sup>-3</sup> (N4–6, sp<sup>2</sup>(π→σ\*) [1, 7]); **8**–(4.4–4.6) eV, 0.3 eV, 7⋅10<sup>19</sup> cm<sup>-3</sup> (Σ →Σ\*) [1, 6, 7]). The defects are distributed both in crystallites and at the intercrystalline PDF boundaries.





**Figure 1.** The absorption spectra  $\alpha$ (hv) of PDF with the side of the substrate  $(1-3)$  and growth  $(4, 5)$  at the edge  $(1, 2, 5)$  and in the deposition center (3, 4) and their approximation (2) with the equation (5) at  $E_{g0} = 2.6$  eV and  $\sigma = 1.8$  eV.

**Figure 2.** The spectra of interband PDF absorption with indirect (1) and direct allowed transitions (2, 3) through the optical gaps  $E_{g}$ and  $E'_{g}$ , respectively.

The photosensitivity spectra  $K(hv)$  are similar to the film absorption spectra and typical to the diamond films  $[1, 4, 9, 11]$ . The spectra  $K(hv)$  are determined by the electron transitions between the valence band and defect LS. Some definite contribution to  $K(hv)$  is made by the transitions between the "tails" of the LS of the allowed bands and the levels associated with the graphite-like phases [1, 11]. The oxygen molecules adsorbed on the film surface facilitate the increase in UV photosensitivity due to their passivating action on defect LS [11].



**Figure 3.**  $E_{g0}(E'_{g})$  (1) vs.  $E_{U}(E'_{g})$  (2, 3) in PDF. The value  $E_{g0}$  is calculated within the interval hv=1.2–5 eV,  $E_g'$  within the interval hv=1.5–3.4 eV, and  $E_U$  within the interval hv=1.18–1.3 (2) and 1.8-2.3 eV (3)



**Figure 4.**  $\alpha'_{0}(E_{g0})$  (1) vs. B'( $E_{g0}$ ) (2) in PDF. The value  $E_{g0}$  is calculated within the interval h $v=1.2-5$  eV, and the value B<sup>'</sup> within the interval  $hv=1.5-3.4$  eV.

Volt-ampere characteristics, field dependence of photosensitivity K(U), energy and kinetic characteristics of electrotransfer  $\varepsilon_{\sigma}$ ,  $\sigma_0$ ,  $T_0$ ,  $\sigma'$ <sub>0</sub>, N(E<sub>F</sub>), I<sub>PhTSC</sub> vary in the thickness and in the PDF deposition plane caused by the heterogeneity of their properties [11]. The temperature dependencies of  $\sigma$ ,  $\Delta\sigma_{ph}(T)$  within the interval T=300–600 K are determined by the thermally stimulated electron exchange between the shallow donor levels with an energy  $\varepsilon_{\sigma}$ =0.007–0.21 eV and the conduction band (CB) [11]. The dominating n-type of  $\sigma$  and  $\Delta\sigma_{ph}$ , as the dependencies I<sub>PhTSC</sub>(T, hv) show [11]. We cannot exclude the effect of the holes exchange between defect LS and the valence band on the characteristics of the films. The electrical parameters indicate the effect on the transport of the hopping conductivity that is verified by the approximation  $\sigma(K)$  by the equation (2) within the interval  $\Delta T$ =300–600 K [11]. The LS density calculated from the dependencies  $\sigma$ ,  $\Delta \sigma_{ph}(T)$  is N(E<sub>F</sub>)=5.6·10<sup>17</sup>– 1.5  $10^{21}$  eV<sup>-1</sup> cm<sup>-3</sup> in PDF with  $\varepsilon_{\sigma}$ =0.007–0.15 eV. In PDF deposited by the alternative methods, the density of LS exponentially distributed near  $E_F$  is N( $E_F$ )=(4–8)⋅10<sup>19</sup> [7, 12] and 10<sup>15</sup>-10<sup>18</sup> eV<sup>-1</sup>⋅cm<sup>-3</sup> [19]. The value of the most probable length of the hop calculated using the values  $N(E_F)$  is R=1.1–8.1 nm and is decreased at lightning to 1.0–6.0 nm under the increase in the density of the states by 3–5 times for the films with electrical conductivity  $\sigma$ <10<sup>-10</sup> S [11].

The correlations between  $\sigma_{p}$   $\sigma_{a}$  and K enable to make the dominance of one of the transport mechanisms [11]. The dominance of  $\sigma_a$  is verified by the dependence  $N(E_F)(\epsilon_{\sigma})$ , which is typical to the noncrystalline semiconductors, which have a high concentration of defects (figure 5) [7, 11, 12, 19]. In PDF, the hopping LS conductivity near  $E_F$  predominates over the activation one at T=300–400 K. When T=400–600 K, the PDF characteristics are determined by  $\sigma_a(T)$  involving LS defects distributed at the grain boundaries and localized in the BG in the region of the "tails" of the allowed bands [11]. When T>600 K, the effect of the energy barrier between crystallites on the transport is increased [11]. The established interrelation between the characteristics  $\sigma_{\epsilon_0}$  and E'<sub>g</sub> agree with the models of the electrotransfer typical for amorphous and highly defect materials [10, 11]. The accumulation of the concentration of absorption centers is related with the decrease in the LS density which participate in the hopping of  $\sigma_p$  from N(E<sub>F</sub>)=10<sup>19</sup> to 5⋅10<sup>17</sup> eV<sup>-1</sup>⋅cm<sup>-3</sup> in the correlation with the increase in  $\alpha$  from 2⋅10<sup>4</sup> to 5⋅10<sup>4</sup> cm<sup>-1</sup> (figures 1 and 5). The decrease in  $\sigma$  and N(E<sub>F</sub>) correlate with the increase in  $\epsilon_{\sigma}$  and  $E_U$  for LS at hv=1.15–1.3 eV and 1.6–3.0 eV (figures 5 and 6). The growth of  $E_U$  from 0.07 to 0.15 eV, as  $\sigma$  is decreased from  $\sigma$ =10<sup>-4</sup> to 10<sup>-11</sup> S and  $\varepsilon_{\sigma}$  is increased from 0.007 to 0.16 eV, is determined



**Figure 5.** Interrelation between LS density and activation energy  $\varepsilon_{\sigma}$  in the deposited films (1, 2) and according to [7] (3). Attenuation constant  $\alpha = 5.7 \cdot 10^6$  (1) and  $2 \cdot 10^7$  cm<sup>-1</sup> (2).



**Figure 6.** Interrelation between conductivity σ, Urbach energy  $E_U$  (1) and activation energy  $\varepsilon_{\sigma}$  and  $E_{U}$  (2) in the deposited films. The values  $E_U$  are calculated within the interval  $hv=1.15-1.3$  eV.

by the impact of the structural disorder induced by defects in the film material and the impact of the disordered graphite-like phases [10, 11]. In the film material BG, the LS energy exponential distribution is formed, LS are induced by the growth defects [1, 10, 11].

## **4. Conclusion**

The properties of the films deposited from AGD do not yield to those of the diamond films obtained by the alternative methods. PDF absorption deposited from the AGD plasma is determined by the continuous LS spectrum induced by different imperfections. The edge of PDF absorption when 5.0– 5.6 eV is separated from the absorption zone within the interval 1.1–5.0 eV induced by defect LS. The BG width is narrowed to  $E_g = 5.0 - 5.3$  eV. The absorption in the energy interval of 1.0–5.0 eV is realized with the transitions between defect LS and interband transitions which are typical to the crystalline and amorphous materials. A new edge of absorption is formed in the films in the energy interval of 1.2–3.3 eV, where the Urbach rule is followed the interband absorption is realized by the direct and indirect transitions. The electrical characteristics of the films are determined by the structural disorder induced by the growth defects in crystallites and by the presence of graphite-like phases in the films. The ntype conductivity activation component is realized when the electrons are exchanged between CB and donor levels with an energy  $\leq 0.21$  eV and is amplified by the LS hopping mechanism near the Fermi level with a density of  $5.6 \cdot 10^{17} - 2.1 \cdot 10^{21}$  eV<sup>-1</sup>·cm<sup>-3</sup>.

## **Acknowledgments**

The paper has been completed within megaproject of National Research Tomsk Polytechnic University (VIU\_IHTPh\_85\_2014) «Materials for Extreme Conditions».

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